

L Number	Hits	Search Text	DB	Time stamp
1	1	("6218248").PN.	USPAT; US-PGPUB	2004/01/27 13:11
2	3	((("5929488") or ("5889293") or ("20010025991"))).PN.	USPAT; US-PGPUB	2004/01/27 13:12
3	3	((("6372562") or ("5889293") or ("6303414"))).PN.	USPAT; US-PGPUB	2004/01/27 14:15
4	8575	SOI and contact	USPAT; US-PGPUB	2004/01/27 15:06
5	6884	(SOI and contact) and (doped or implanted or doping or implanting)	USPAT; US-PGPUB	2004/01/27 15:06
6	5325	((SOI and contact) and (doped or implanted or doping or implanting)) and (gate or electrtode)	USPAT; US-PGPUB	2004/01/27 15:06
7	5060	((SOI and contact) and (doped or implanted or doping or implanting)) and (gate or electrtode)) and (source or drain)	USPAT; US-PGPUB	2004/01/27 15:07
8	3311	((SOI and contact) and (doped or implanted or doping or implanting)) and (gate or electrtode)) and (source or drain)) and (opening or hole or recess or aperture)	USPAT; US-PGPUB	2004/01/27 15:07
9	2533	((SOI and contact) and (doped or implanted or doping or implanting)) and (gate or electrtode)) and (source or drain)) and (opening or hole or recess or aperture)) and @ad<20011115	USPAT; US-PGPUB	2004/01/27 14:18
10	1316	((SOI and contact) and (doped or implanted or doping or implanting)) and (gate or electrtode)) and (source or drain)) and (opening or hole or recess or aperture)) and @ad<20011115) and (gate adj (insulative or insulated or insulator or insulating or dielectric))	USPAT; US-PGPUB	2004/01/27 14:21
11	1163	SOI and contact	EPO; JPO; DERWENT; IBM_TDB	2004/01/27 15:06
13	284	(SOI and contact) and (doped or implanted or doping or implanting)	EPO; JPO; DERWENT; IBM_TDB	2004/01/27 15:06
14	140	((SOI and contact) and (doped or implanted or doping or implanting)) and (gate or electrtode)	EPO; JPO; DERWENT; IBM_TDB	2004/01/27 15:07
15	101	((SOI and contact) and (doped or implanted or doping or implanting)) and (gate or electrtode)) and (source or drain)	EPO; JPO; DERWENT; IBM_TDB	2004/01/27 15:07
16	24	((SOI and contact) and (doped or implanted or doping or implanting)) and (gate or electrtode)) and (source or drain)) and (opening or hole or recess or aperture)	EPO; JPO; DERWENT; IBM_TDB	2004/01/27 15:07